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Application No.:10/728,135

Docket No.:JCLA12578-R

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Examiner: Chacko Davis, Daborah
Group Art Unit: 1795In re PATENT APPLICATION of
Applicants : Chang et al.

Serial No. : 10/728,135

Filed : December 03, 2003

For : IMMERSION LITHOGRAPHY PROCESS
AND MASK LAYER STRUCTURE
APPLIED IN THE SAMEAMENDMENTAMENDMENT AAFTER FINALMAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated February 11, 2008, please enter the following amendments and consider the following remarks.